

NDK High Purity Crystalline Quartz Products

EPIC Technology Meeting on Innovative Optics

June 25th, 2025

Nihon Dempa Kogyo Co., Ltd.



Company Overview



CONFIDENTIAL

Corporate Name	NIHON DEMPA KOGYO CO., LTD.
Activities	Production and sales of Crystal-Related products such as Crystal devices (e.g. Crystal Units, Crystal Oscillators, Crystal filters), Ultrasonic Transducers, Synthetic Quartz and Crystal Blank.
Date of Foundation	Apr-1948
Representative Director and President	Hiromi Katoh
Share Capital	¥5.596 billion (As of March 31, 2025)
Number of Shares Issued	Common Stock : 23,128,605 shares (As of March 31, 2025)
Stock Listing	Prime Market, Tokyo Stock Exchange (code:6779)
Annual Sales	Consolidated (IFRS) ¥53.064 billion(Fiscal Year Ended March 31, 2025)
Number of Employees	NDK 674 / Group 2,334 (As of March 31, 2025)
Head Office	Merkmal Keio Sasazuka Bldg., 1-47-1, Sasazuka, Shibuya-ku, Tokyo, 151-8569, Japan
Sayama Plant	1275-2, Kamihirose, Sayama-city, Saitama 350-1321, Japan

Production and R&D bases



Japan



● Eniwa Office
[Eniwa City, Hokkaido]



● Chitose Technical Center
[Chitose City, Hokkaido]



● Hakodate NDK Co., Ltd.
[Hakodate, Hokkaido]



● Furukawa NDK Co., Ltd.
[Osaki City, Miyagi Prefecture]



● Sayama Plant
[Sayama City, Saitama Prefecture]

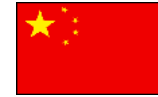


head office
[Shibuya-ku, Tokyo]



● Tokyo Office
[Tokyo]

- Production bases
- R&D bases



China



● Suzhou NDK Co., Ltd.



UK

● Parts Development



Malaysia



- Asian NDK Crystal Sdn.Bhd (ANC)
- NDK Quartz Malaysia Sdn.Bhd. (NQM)



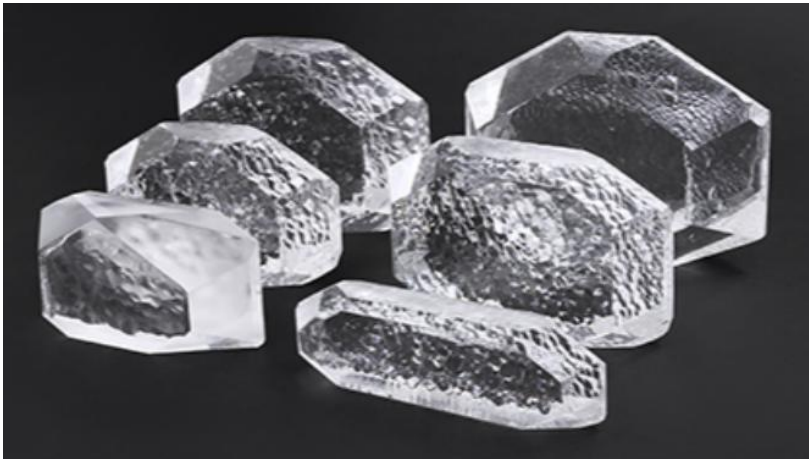
Sales Offices

We have sales offices all over the world and have established partnerships with our customers globally.



Synthetic Quartz Crystal

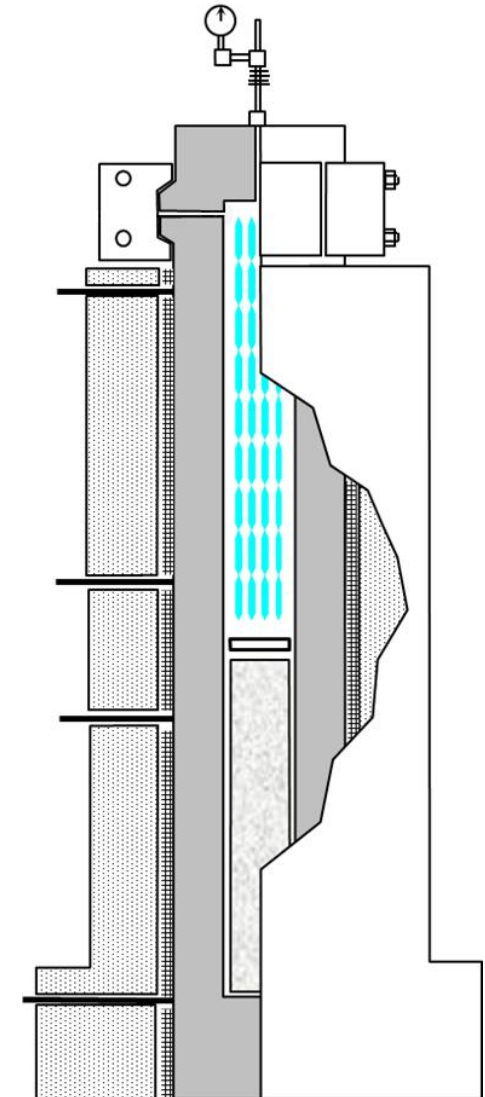
Synthetic quartz crystals are grown by hydrothermal synthesis in a high-temperature, high-pressure vessel called an autoclave.



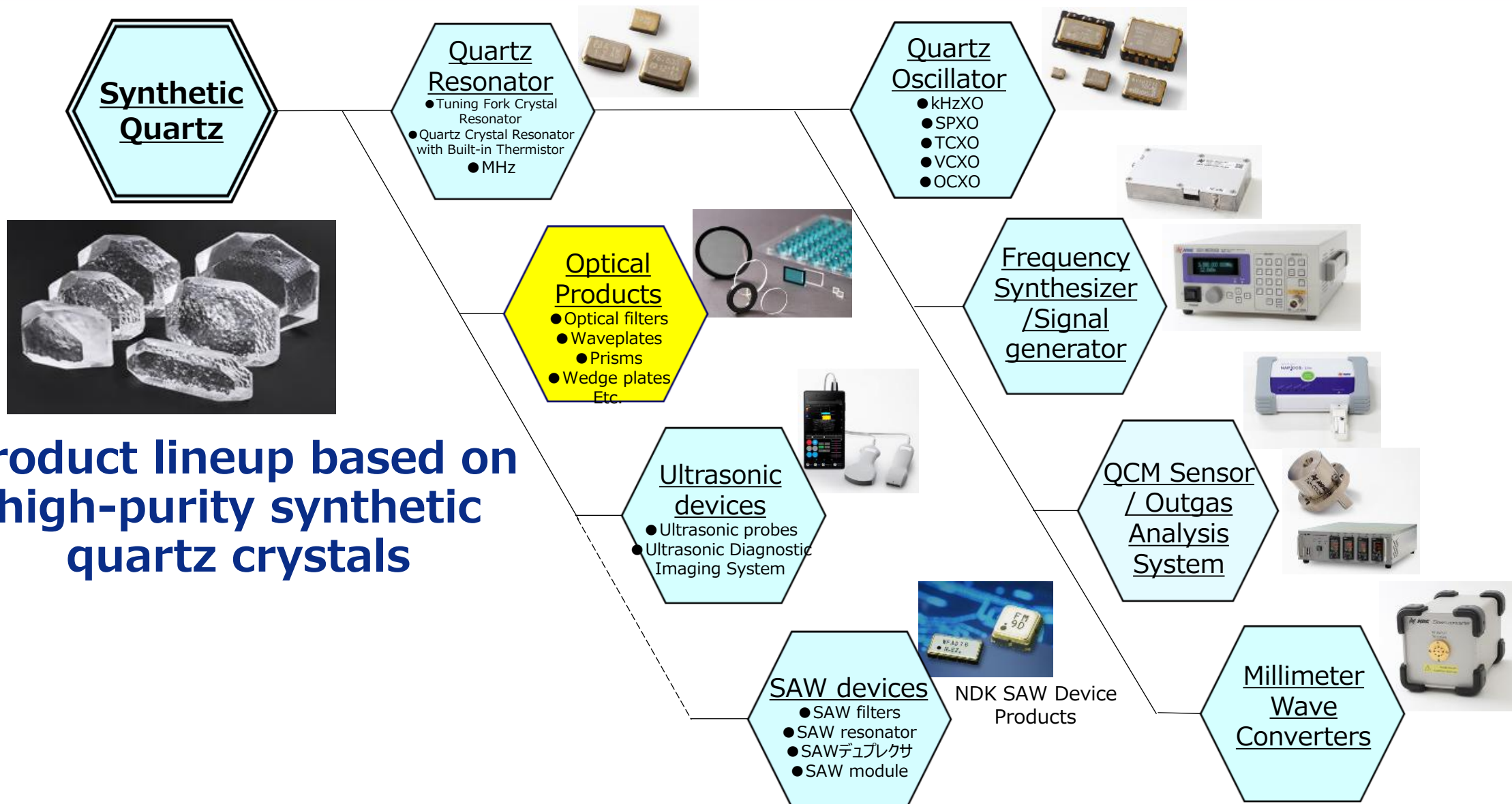
Synthetic Quartz Crystal



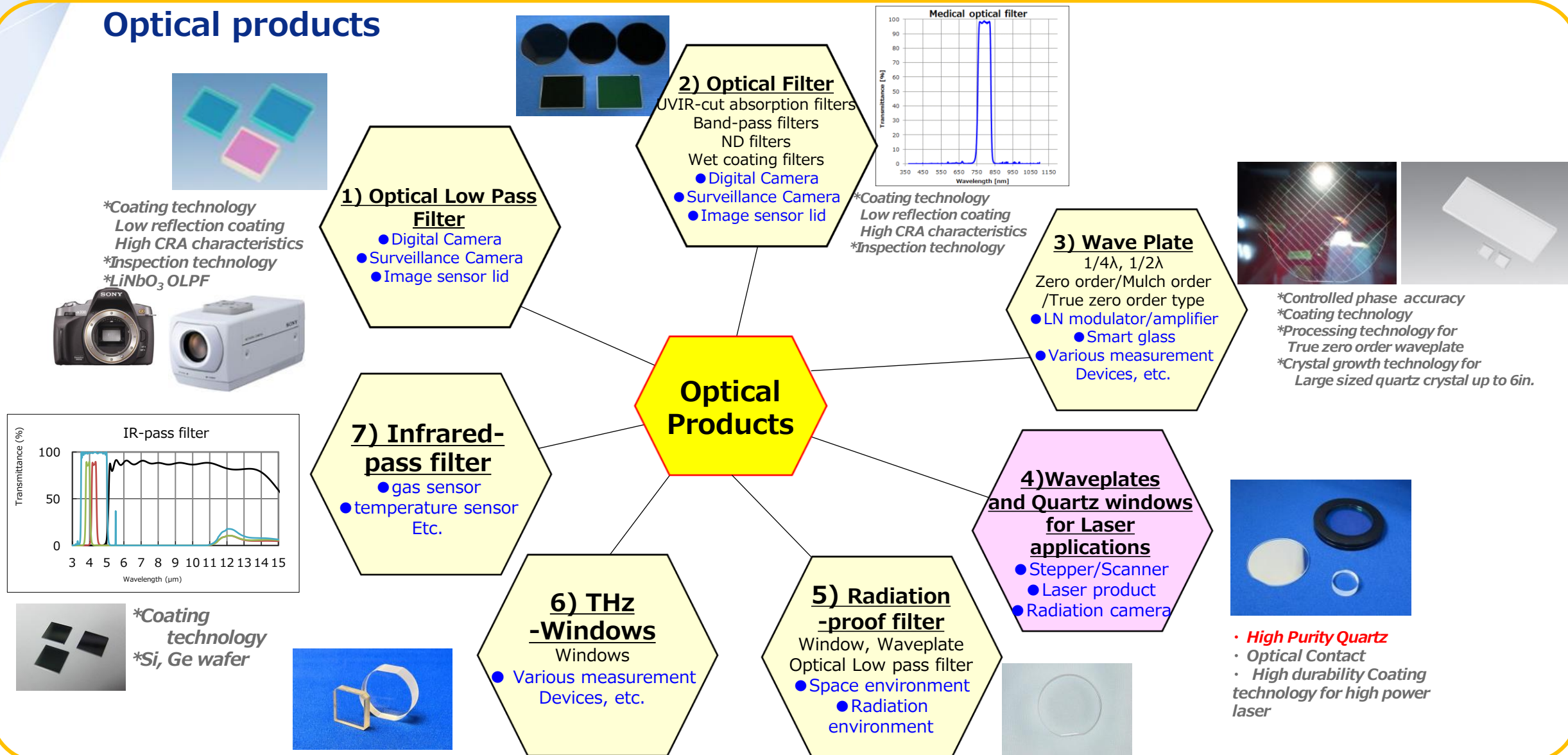
Unloading synthetic quartz crystal



Schematic of autoclave



Optical products




No degradation formation under UV and Radiation:
Maintains transparency, resists laser-induced darkening.

Items	Quartz Glass	Quartz Crystal
Crystal structure	Amorphous (non-crystalline) SiO ₂	Synthetically grown crystalline SiO ₂
Atomic array	No atomic order (optically isotropic)	Has a regular, repeating atomic lattice (crystalline, trigonometric system)
Purity	99.9999%(6N) Highest purity	99.99999%(7N) N-Grade EX


Impurity-free NDK crystal : Remains clear even after prolonged exposure in nuclear reactors.

Radiation exposure test


未照射
unexposed




31MGy




No degradation

 **N-Grade EX**
Ultra-High Purity

unexposed



180KGy





Blackening occurred

【Optical/Laser Grade】
Common Purity

※ The measurement and evaluation of Gamma-ray irradiation test is achieved with the cooperation of Professor Kouichi Kajiwara of Tokyo Metropolitan University.
•⁶⁰Coγ-ray irradiation (National Institutes for Quantum Science and Technology)
•2020-4-3~2020-10-30 (Maximum radiation dose 31MGy)

NDK's "N-Grade EX" Represents **the World's Highest-Purity** Synthetic Quartz Crystal.

Quartz Grade	Inclusion density	α value	Etch channel density	Al contents (ppb)
① N-Grade EX 	◎ (Grade.Ia)	◎ (Grade.Aa)	◎ (Grade.1aa)	19
② N-Grade 	◎ (Grade.Ia)	○ (Grade.A)	○ (Grade.1)	70
③ Laser Grade	◎ (Grade.Ia)	△ (Grade.C)	×	(4,600)
④ For Crystal Frade	△ (Grade.II)	△ (Grade.C)	○ (Grade.1)	(4,600)
⑤ SAW Grade	△ (Grade.II)	△ (Grade.C)	○ (Grade.1)	(4,600)

<JIS C 6704 spec.>

Inclusion Density

Units: pc./cm²

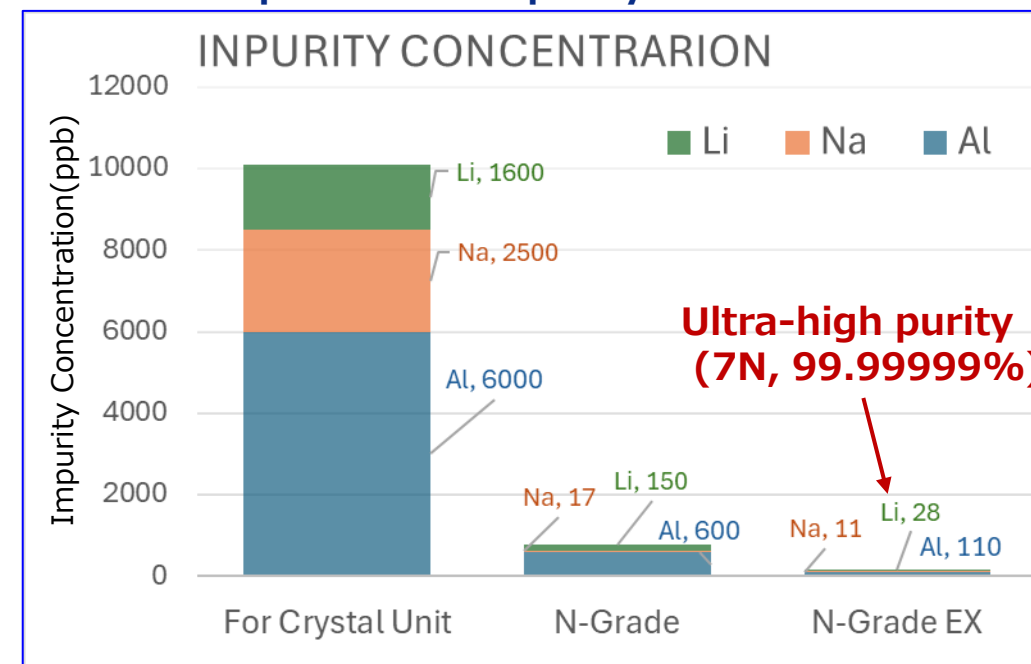
Grade		Ia	Ib	I	II	III
Inclusions	>100μm	0	1	2	3	4
	70-100μm	0	1	2	4	6
	30-70μm	1	2	4	5	8
	10-30μm	2	3	6	9	12

α -Value/Infrared Absorption Coefficient

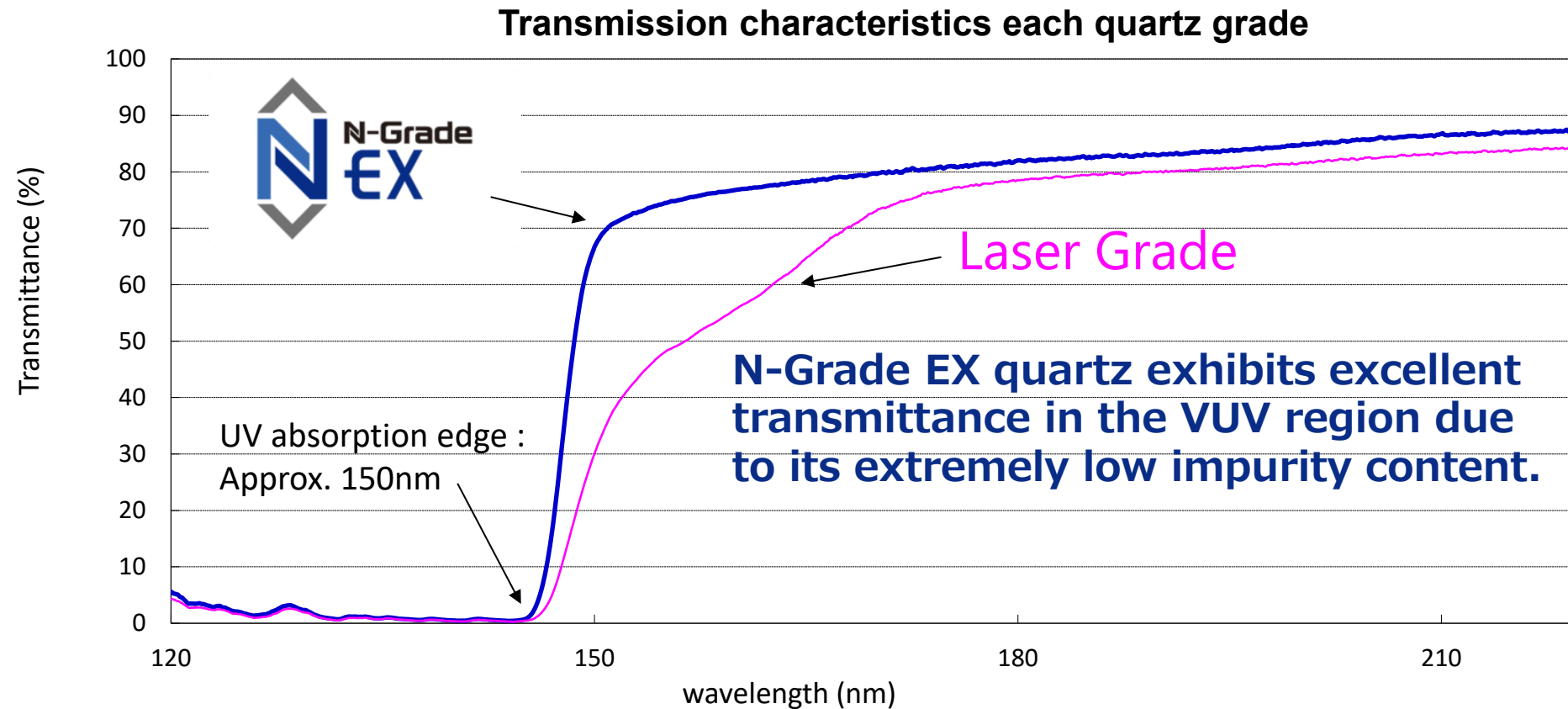
Measured by infrared spectrophotometry to quantify IR attenuation.

Grade	Aa	A	B	C	D	E
α_{3585}	0.015	0.024	0.050	0.069	0.100	0.140
Applications	High stability crystal oscillator			High stability crystal oscillator for industrial use		Low frequency oscillator

Comparison of Impurity Concentrations



Quartz products made from ultra-high-purity “N-Grade EX” exhibit **high laser damage thresholds in the EUV range**, demonstrating outstanding performance as optical components for lithography equipment.

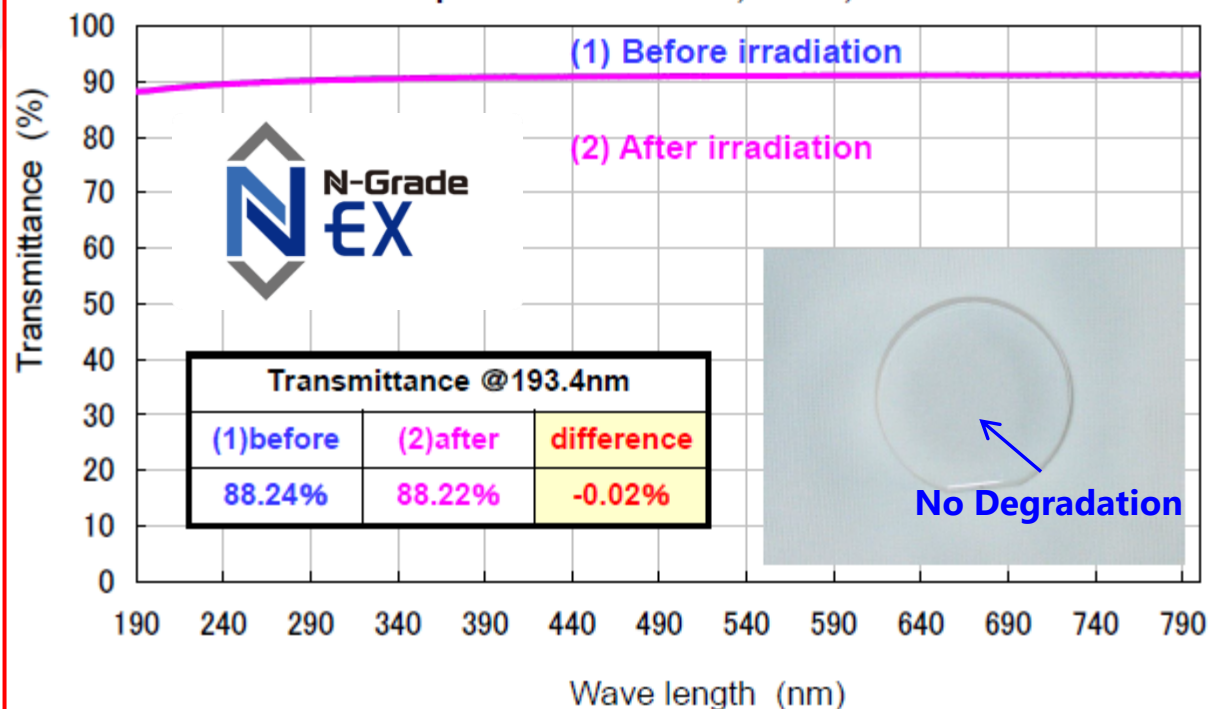


Correlation Between Spectral Transmittance in the VUV Region and Q Value

“N-Grade EX” quartz **maintain high transmittance** and exhibit **no degradation** under laser irradiation, unlike Laser-grade quartz.

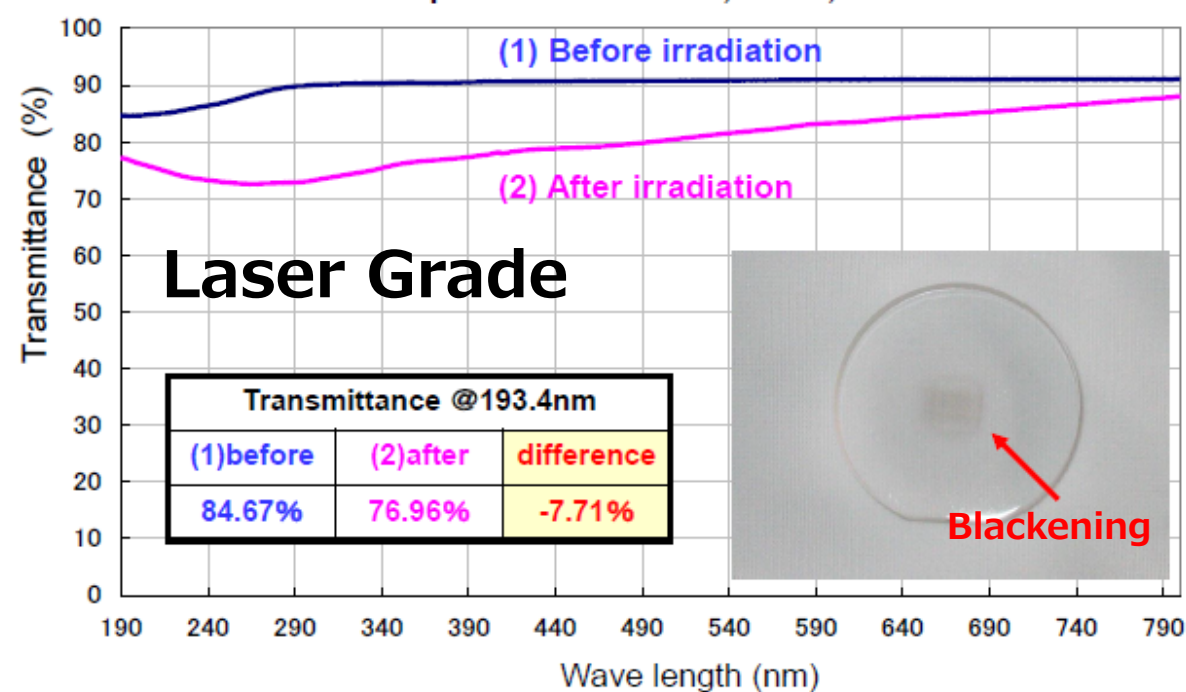
➤ Higher quality quartz

➤ ArF excimer laser power: $50\text{mJ}/\text{cm}^2$, 100Hz, 1×10^5 shots



➤ Regular quartz

➤ ArF excimer laser power: $50\text{mJ}/\text{cm}^2$, 100Hz, 1×10^5 shots

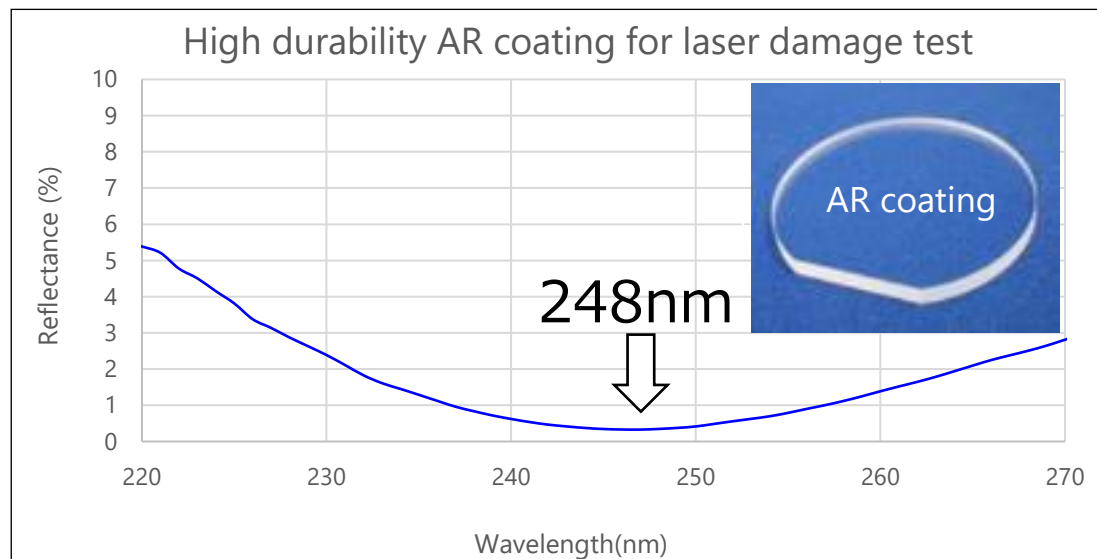


Laser irradiation conditions ; ArF(193nm) Excimer laser 、 $50\text{mJ}/\text{cm}^2$, 100Hz, 1×10^5 shot

(1) Before Test

(2) After Test

Laser damage resistance evaluation of 248nm waveplates



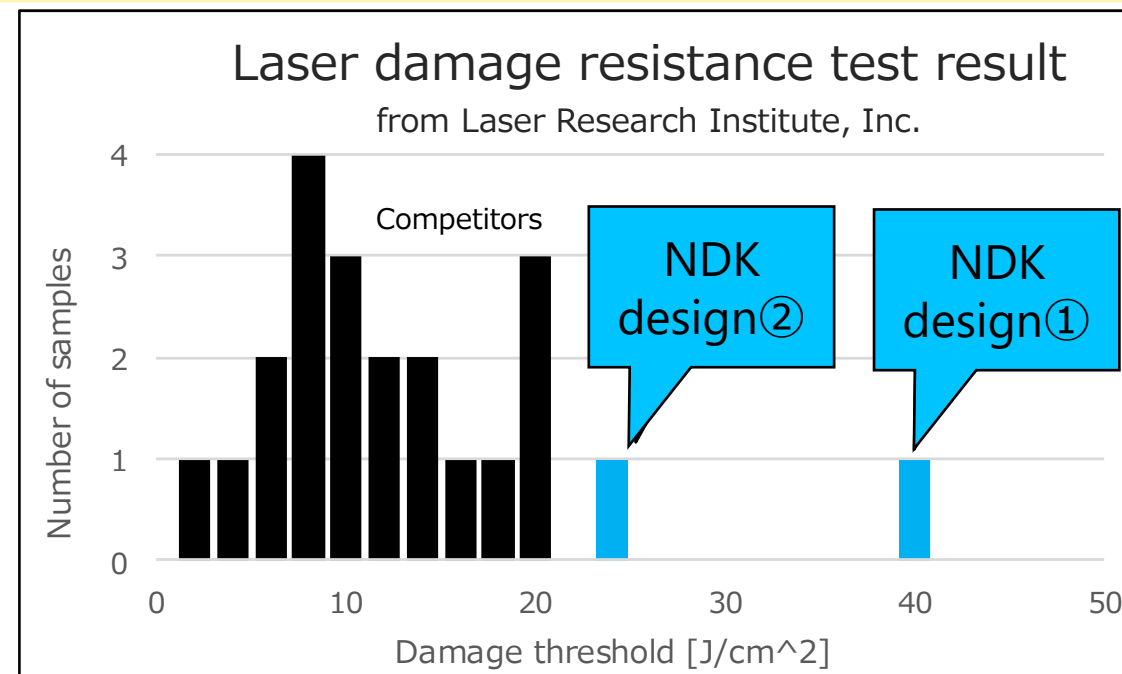
In addition to its ultra-high-purity quartz “N-Grade EX,” NDK possesses advanced substrate processing technologies and coating design/manufacturing capabilities, enabling the production of quartz optical components with top-tier laser resistance.

Available wavelength: 193nm to 1550nm

Laser damaged threshold value

DTp=40 [J/cm²] (actual value)

@248nm, 10nsec, 10Hz, 1000 on 1

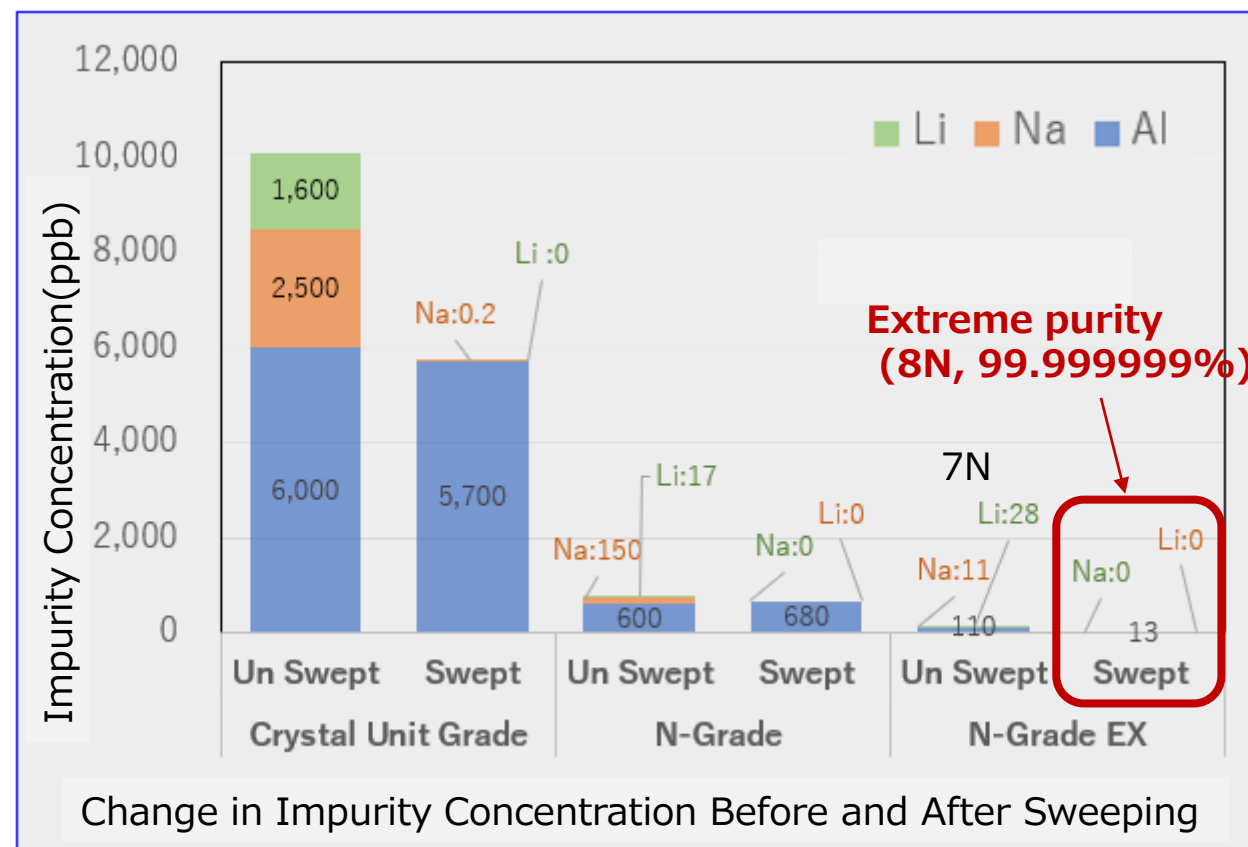
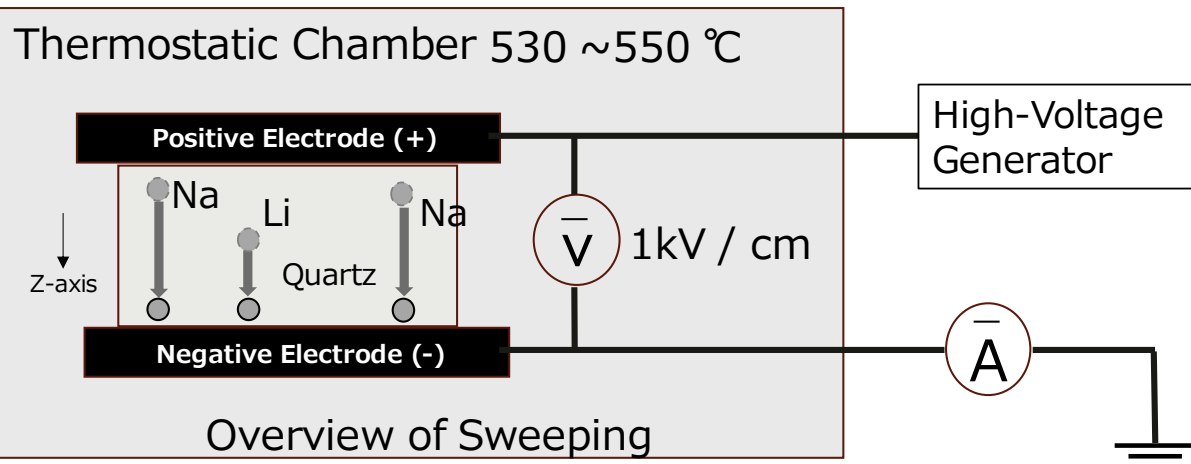


※ NDK design① : N-Grade EX + Coating A
NDK design② : N-Grade EX + Coating B

NDK is actively developing “Sweeping Quartz” to achieve even higher levels of quartz purity.

【Sweeping】

High-temperature, high-voltage processing removes Na and Li impurities from quartz.



Gaseous components released from organic materials that make up products, such as plastics and adhesives, are called "outgassing (volatile gases)."

To prevent contamination problems in space and product defects, it is important to accurately measure outgassing, select materials with less outgassing, and understand long-term trends in gas emissions.

In recent years, the demand for miniaturization, high precision, and high reliability of parts has led to an increase in the use of outgassing detection, and it is also attracting attention in general industrial applications.

Impact of outgassing on electronic devices

Electronic Devices	Effects of outgassing
Optical machine	Image quality degradation
Solar Cell	Decreased amount of incident light
Relays, Switches	Poor contact
motor	Poor start
Quartz Crystal	Oscillation frequency drop

Main applications of outgassing detection and analysis

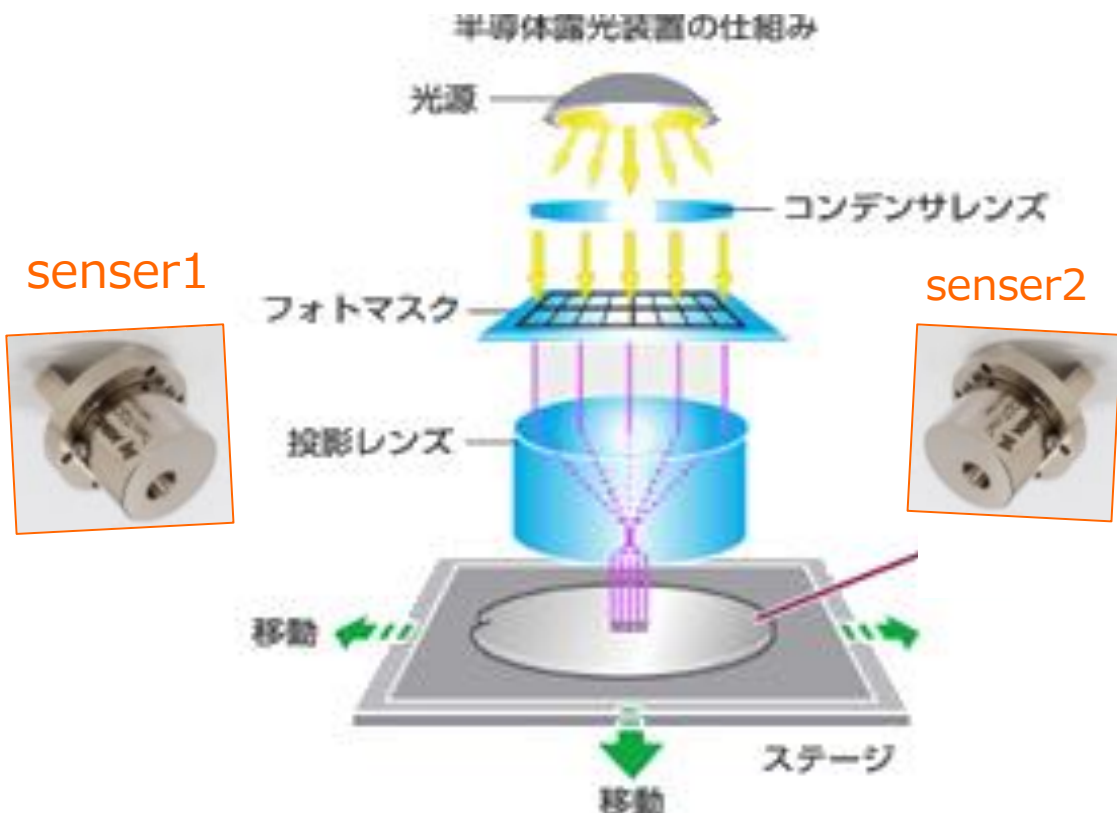
- spacecraft components
- Development of optical equipment, automotive parts, and automotive materials
- Material analysis and evaluation, outgassing analysis (Parts acceptance, shipping inspection)
- Development of organic materials
- vacuum chamber environmental evaluation (Sensing)
- Film formation and abnormality monitoring for semiconductor manufacturing equipment,

Outgas sensor application fields

Example of QCM sensor application to semiconductor exposure equipment

半導体露光装置用レンズ
汚染モニタ用センサの実装例

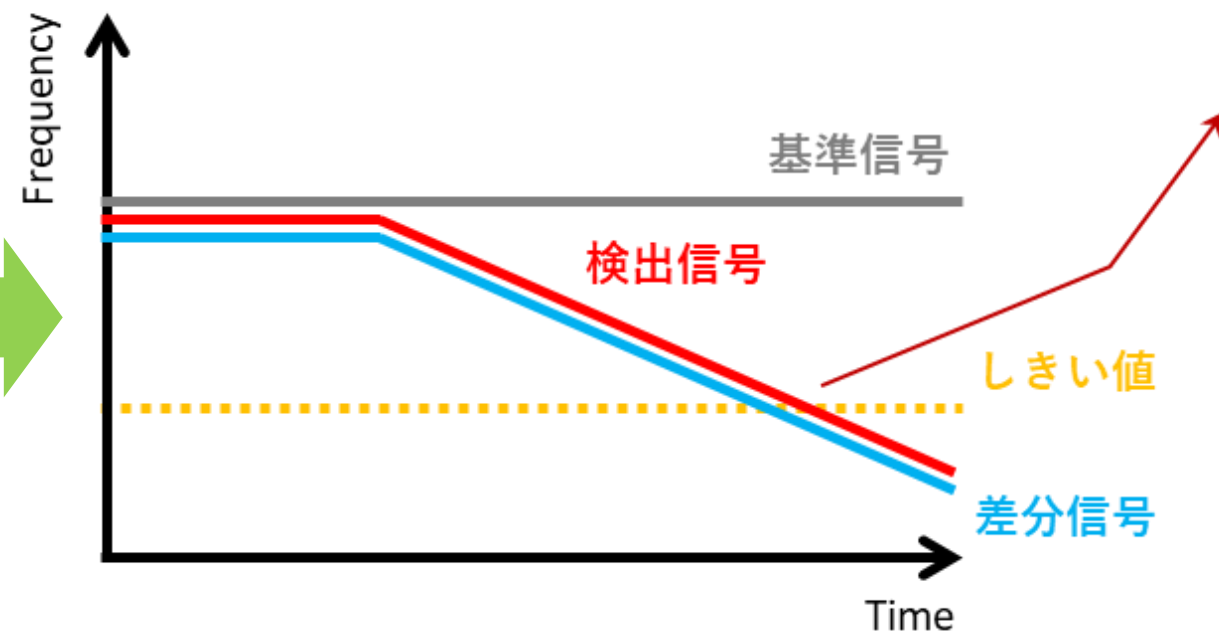
半導体露光装置の仕組み



Install a sensor inside the semiconductor exposure equipment to monitor the lens contamination status (at one specific location or multiple locations)

Example of application as QCM for dirt and cloudiness of the light detection part

The frequency of the detection signal decreases according to the level of contamination inside the device, and the threshold value decreases after a certain period of use.



Set an arbitrary threshold value to monitor lens contamination. When the frequency of the detection signal falls below the threshold, the lens is cleaned or replaced to prevent in-process defects.

**Thank you very much
for your attention.**